

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	(substrate and bump and etching and insulating and electroplating and mask and barrier and patterns).clm.	US-PGPUB	ADJ	ON	2006/03/26 13:15
L2	1	(substrate and bump and etching and insulating and electroplating and mask and barrier and patterns and concavity).clm.	US-PGPUB	ADJ	ON	2006/03/26 13:16
L3	1	(substrate and bump and etching and insulating and electroplating and mask and barrier and patterns and power).clm.	US-PGPUB	ADJ	ON	2006/03/26 13:16

INT. SEARCH

→ current application